L Number	Hits	Search Text	DB	Time stamp
-	3	(("6204608") or ("6593624") or ("6759712")).PN.	USPAT;	2004/11/04
			US-PGPUB;	09:58
			IBM_TDB	
_	51	Bhattacharyya-Arup.in.	USPAT;	2004/11/04
			US-PGPUB;	09:46
			IBM_TDB	
-	5	recrystallization.clm. and Bhattacharyya-Arup.in.	USPAT;	2004/11/04
		, , , , , , , , , , , , , , , , , , , ,	US-PGPUB;	09:50
			IBM_TDB	
_	4	(("4692994") or ("4768076") or ("5006913") or	USPAT;	2004/11/04
		("6429085")).PN.	US-PGPUB;	09:50
	,	(0 129000)) 14.	IBM_TDB	
_	l. 1	("6204608").PN.	USPAT;	2004/11/04
	•	(0204000).F14.	US-PGPUB;	09:54
				05.54
		(/ 20020012205) (20020015212)	IBM_TDB	2004/11/04
-	3	(("20030013305") or ("20020045312") or	USPAT;	2004/11/04
		("20020014625")).PN.	US-PGPUB;	09:54
			IBM_TDB	
-	3501	((257/347,616) or (438/164,166,933)).CCLS.	USPAT;	2004/11/04 11:06
			US-PGPUB;	
			IBW_TDB	
-	2941	(((257/347,616) or (438/164,166,933)).CCLS.) and	USPAT;	2004/11/04 11:13
		@ad<20020912	US-PGPUB;	
			IBM_TDB	
-	2887	((((257/347,616) or (438/164,166,933)).CCLS.) and	USPAT;	2004/11/04 11:13
	·	@ad<20020912) not micron.as.	US-PGPUB;	
			IBM_TDB	
-	19185	SiGe "silicon germanium"	USPAT;	2004/11/04 11:07
		•	US-PGPUB;	
			IBM_TDB	
-	1284	relaxed and strained	USPAT;	2004/11/04 11:07
			US-PGPUB;	
			IBM_TDB	
_	70451	połysilicon polySi	USPAT;	2004/11/04 11:07
			US-PGPUB;	
			IBM_TDB	
	70665	silicon adj oxide	USPAT;	2004/11/04 11:07
			US-PGPUB;	
			IBM_TDB	
_	87915	silicon adj dioxide	USPAT;	2004/11/04 11:07
	5,313	ו אוייטוו מען שוטאועט	US-PGPUB;	L00-7/11/0- 11.0/
			IBM_TDB	
_	165739	vaid (amall with amoral)	USPAT;	2004/11/04 11:08
-	105/39	void (small with crystal)		2004/11/04 11:08
			US-PGPUB;	
	17/02	Mattheward: and A. Vatter and A. Herrich No. 17, 17	IBM_TDB	2004/44/04/44 02
•	17602	((silicon adj oxide) (silicon adj dioxide)) and (void	USPAT;	2004/11/04 11:08
		(small with crystal))	US-PGPUB;	
			IBM_TDB	
-	2568	((silicon adj oxide) (silicon adj dioxide)) same (void	USPAT;	2004/11/04 11:08
		(small with crystal))	US-PGPUB;	
			IBM_TDB	

		<u></u>		
-	308225	nickel Ni	USPAT;	2004/11/04 11:08
			US-PGPUB;	
			IBM_TDB	
-	23559	((O oxygen) (helium He)) same (doped doping	USPAT;	2004/11/04 11:09
		implantation)	US-PGPUB;	
			IBM_TDB	
-	321	(((silicon adj oxide) (silicon adj dioxide)) same (void	USPAT;	2004/11/04 11:09
		(small with crystal))) and (((O oxygen) (helium He))	US-PGPUB;	
		same (doped doping implantation))	IBM_TDB	
i	57	((((silicon adj oxide) (silicon adj dioxide)) same (void	USPAT;	2004/11/04 11:09
		(small with crystal))) and (((O oxygen) (helium He))	US-PGPUB;	
		same (doped doping implantation))) and (nickel Ni)	IBM_TDB	
_	7	(((((silicon adj oxide) (silicon adj dioxide)) same (void	USPAT;	2004/11/04 11:10
		(small with crystal))) and (((O oxygen) (helium He))	US-PGPUB;	
		same (doped doping implantation))) and (nickel Ni))	IBM_TDB	
		and (SiGe "silicon germanium")	1000_100	
	149	(SiGe "silicon germanium") and (relaxed and strained)	USPAT;	2004/11/04 11:10
	147	and (polysilicon polysi)	US-PGPUB;	2004/11/04 11:10
			IBM_TDB	
	4	((SiGe "silicon germanium") and (relaxed and	USPAT;	2004/11/04 11:10
-	7	···		2004/11/04 11:10
		strained) and (polysilicon polysi)) and (((silicon adj	US-PGPUB;	
		oxide) (silicon adj dioxide)) same (void (small with	IBM_TDB	
	2/5	crystal)))	LICDAT.	2004/41/04 44:24
-	265	((((((silicon adj oxide) (silicon adj dioxide)) same (void	USPAT;	2004/11/04 11:21
		(small with crystal))) and (((O oxygen) (helium He))	US-PGPUB;	
		same (doped doping implantation))) and	IBM_TDB	
	40440	@ad<20020912) not micron.as.		
-	68612	recrystallization re-crystallization	USPAT;	2004/11/04 11:13
			US-PGPUB;	
			IBM_TDB	
-	1027	(SiGe "silicon germanium") and (recrystallization	USPAT;	2004/11/04 11:13
		re-crystallization)	US-PGPUB;	
			IBW_LDB	
-	384	((SiGe "silicon germanium") and (recrystallization	USPAT;	2004/11/04 11:13
		re-crystallization)) and (nickel Ni)	US-PGPUB;	
1			IBM_TDB	
-	278	((((silicon adj oxide) (silicon adj dioxide)) same (void	USPAT;	2004/11/04 11:21
		(small with crystal))) and (((O oxygen) (helium He))	US-PGPUB;	
		same (doped doping implantation))) and	IBM_TDB	
		@ad<20020912		
-	27	(((SiGe "silicon germanium") and (recrystallization	USPAT;	2004/11/04 11:17
		re-crystallization)) and (nickel Ni)) and (relaxed and	US-PGPUB;	
		strained)	IBM_TDB	
-	3	(("6690038") or ("6713810") or ("6727529")).PN.	USPAT;	2004/11/04 11:17
			US-PGPUB;	
		•	IBM_TDB	
-	. 4	(("4692994") or ("4768076") or ("5006913") or	USPAT;	2004/11/04 11:18
		("6429085")).PN.	US-PGPUB;	
			IBM_TDB	
-	4	(("5428238") or ("5583359") or ("6236078") or	USPAT;	2004/11/04 11:19
		("6476432")).PN.	US-PGPUB;	
			IBM_TDB	

_	1	("5825064").PN.	USPAT;	2004/11/04 11:20
		•	US-PGPUB,	
			IBM_TDB	
-	5	(("4375085") or ("5483094") or ("5659504") or	USPAT;	2004/11/04 11:20
	1	("6607948") or ("6812504")).PN.	US-PGPUB;	
			IBM_TDB	
-	17	((("6690038") or ("6713810") or ("6727529")).PN.)	USPAT;	2004/11/04 11:21
		((("4692994") or ("4768076") or ("5006913") or	US-PGPUB;	
		("6429085")).PN.) ((("5428238") or ("5583359") or	IBM_TDB	
		("6236078") or ("6476432")).PN.) (("5825064").PN.)		
)	((("4375085") or ("5483094") or ("5659504") or		
	1	("6607948") or ("6812504")).PN.)		
-	15	(((("6690038") or ("6713810") or ("6727529")).PN.)	USPAT;	2004/11/04 11:21
	1	((("4692994") or ("4768076") or ("5006913") or	US-PGPUB;	,
		("6429085")).PN.) ((("5428238") or ("5583359") or	IBM_TDB	
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		("6607948") or ("6812504")).PN.)) and		
		@ad<20020912		
-	14	((((("6690038") or ("6713810") or ("6727529")).PN.)	USPAT;	2004/11/04 11:21
		((("4692994") or ("4768076") or ("5006913") or	US-PGPUB;	
		("6429085")).PN.) ((("5428238") or ("5583359") or	IBM_TDB	!
		("6236078") or ("6476432")).PN.) (("5825064").PN.)		
		((("4375085") or ("5483094") or ("5659504") or		
		("6607948") or ("6812504")).PN.)) and		
		@ad<20020912) not micron.as.		